

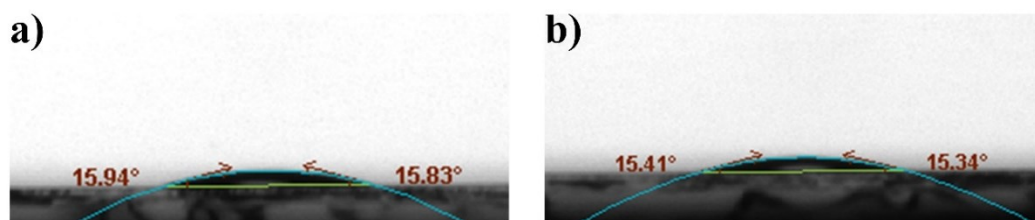
## Supporting Information

### **Bifacial Passivation towards Efficient FAPbBr<sub>3</sub>-based Inverted Perovskite Light-emitting Diodes**

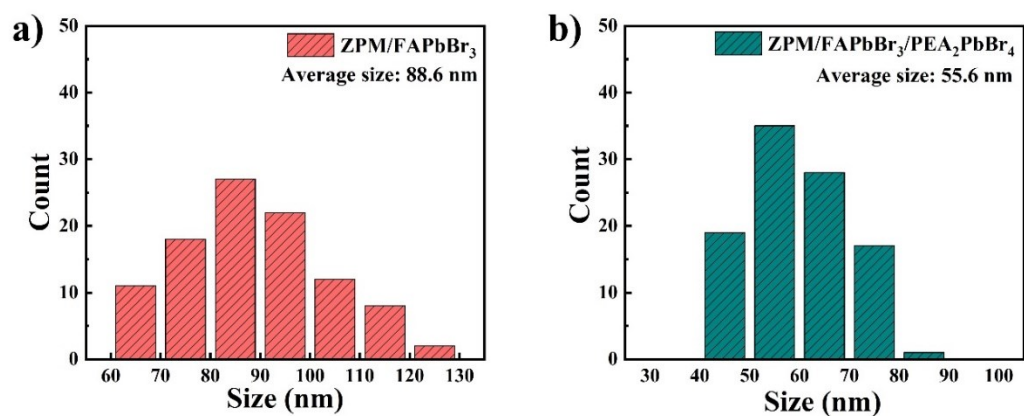
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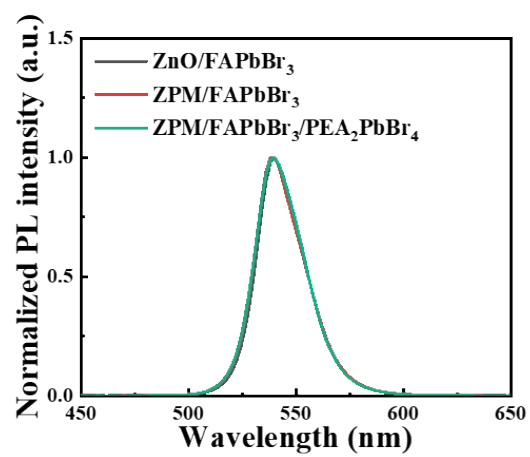
**Figure S1.** Contact angles of a) ZnO film and b) ZPM film.



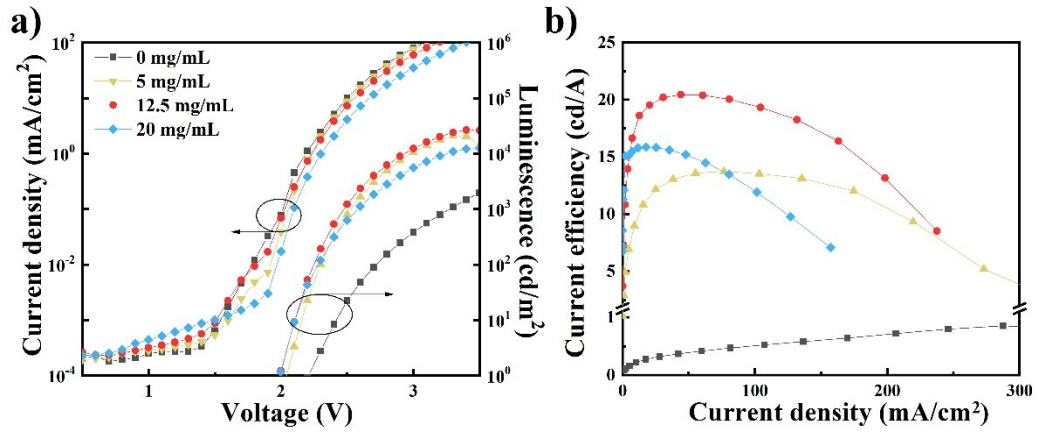
**Figure S2.** Grain size distribution of FAPbBr<sub>3</sub> films deposited on a) ZPM, and b) PEABr-modified FAPbBr<sub>3</sub> film on ZPM.

**Table S1.** Tri-exponential fitting parameters of the photoluminescence decay profiles shown in Figure 5c.

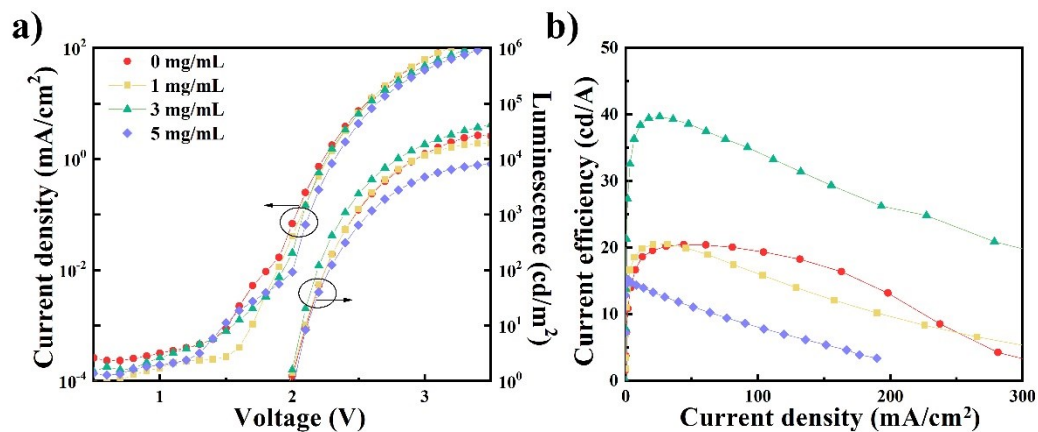
Device	$A_1$ (%)	$\tau_1$ (ns)	$A_2$ (%)	$\tau_2$ (ns)	$A_3$ (%)	$\tau_3$ (ns)	$\tau_{\text{avg}}$ (ns)
ZnO/FAPbBr <sub>3</sub>	15	3.13	49	15.58	36	53.92	27.51
ZPM/FAPbBr <sub>3</sub>	10	5.12	48	23.89	42	80.91	45.87
ZPM/FAPbBr <sub>3</sub> /PEA <sub>2</sub> PbBr	7	6.30	40	39.55	53	135.4	88.08



**Figure S3.** Normalized PL intensity different kinds of perovskite films.



**Figure S4.** Device performance of ZPM/FAPbBr<sub>3</sub> devices with different concentrations of PVP in the PVP solution. a) *J-V-L* characteristics, b) *CE-J* characteristics.

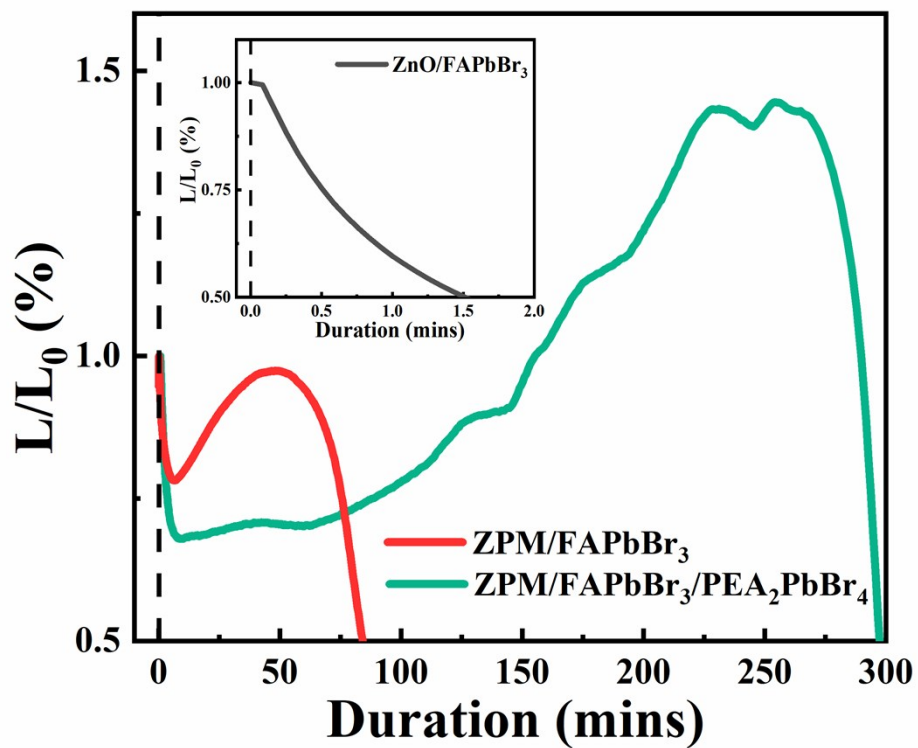


**Figure S5.** Device performance of ZPM/FAPbBr<sub>3</sub>/PEA<sub>2</sub>PbBr<sub>4</sub> devices with different concentrations of PEABr in the PEABr solution (the PVP concentration in the PVP solution is fixed at 12.5 mg/mL). a) *J-V-L* characteristics, b) *CE-J* characteristics.

**Table S2.** Device performance of the inverted green PeLEDs.

<b>Device Structure</b>	<b><math>V_{on}</math> [V]</b>	<b><math>L_{max}</math> [cd/m<sup>2</sup>]</b>	<b><math>EQE_{max}</math> [%]</b>	<b><math>PE_{max}</math> [lm/W]</b>	<b>Ref.</b>
ITO/AZO:Cs/Cs <sub>10</sub> (MA <sub>0.17</sub> FA <sub>0.83</sub> )PbBr <sub>2.97</sub> I <sub>0.003</sub> /CuSGaSnO/ WO <sub>3</sub> /Au	2.5	553370	12.98	89.7	1
ITO/ZnO/PVP/Cs <sub>0.87</sub> MA <sub>0.13</sub> PbBr <sub>3</sub> /CBP/ MoO <sub>x</sub> /Al	2.9	91000	10.4	/	2
ITO/LZO/MIZO/CsPbBr <sub>3</sub> QDs/TCTA/NPD/HAT-CN/Al	2.7	22825	5.7	9.7	3
ITO/a-ZSO/CsPbBr <sub>3</sub> /NPD/MoO <sub>x</sub> /Al	/	496320	9.3	33.0	4
ITO/ZnO/PEI/MAPbBr <sub>3</sub> /TFB/MoO <sub>x</sub> /Al	2.2	20000	0.8	4	5
ITO/ZnO/PMMA/MAPbBr <sub>3</sub> /PVK/NPD/Al	5.0	3450	2.8	4.4	6
ITO/ZnO/FAPbBr <sub>3</sub> /Poly-TPD/MoO <sub>x</sub> /Al	1.9	13062	1.2	3.1	7
ITO/ZnO/PEIE/FAPbBr <sub>3</sub> /TFB/MoO <sub>x</sub> /Al	2.0	7348	3.5	19.1	8
ITO/ZnO/FAPbBr <sub>3</sub> QDs/PVK/Poly-TPD/Pt	4.1	12998	6.0	/	9
<b>ITO/ZPM/FAPbBr<sub>3</sub>/PEA<sub>2</sub>PbBr<sub>4</sub>/PVK/MoO<sub>x</sub> /Al</b>	<b>2.0</b>	<b>60290</b>	<b>9.0</b>	<b>46.4</b>	<b>This work</b>





**Figure S6.** The operational lifetime at initial brightness of  $\sim 100$   $\text{cd}/\text{m}^2$ .

## Supplementary References

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